

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	195	((substrate or wafer or surface) and (carbon or C) and (deuterium or D) and (Si or Ge or B or Sn or Fe or Ti) and ((anneal\$3 or heat\$3) with (hydrogen or deuterium))).CLM.	US-PGPUB	OR	ON	2005/11/03 15:52
L2	2	((substrate or wafer or surface) and carbon and deuterium and (Si or Ge or B or Sn or Fe or Ti) and ((anneal\$3 or heat\$3) with (hydrogen or deuterium))).CLM.	US-PGPUB	OR	ON	2005/11/03 15:53